

Broadband nanoplasmonic photodetector fabricated in ambient condition

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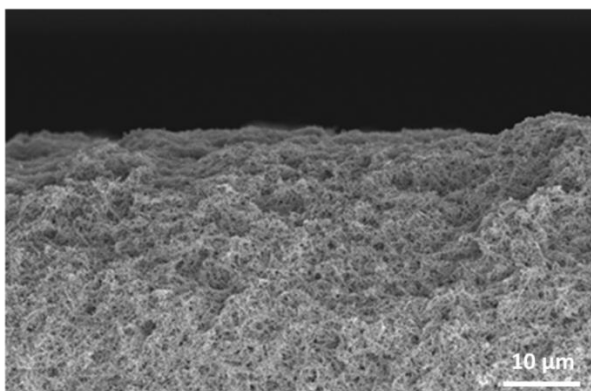
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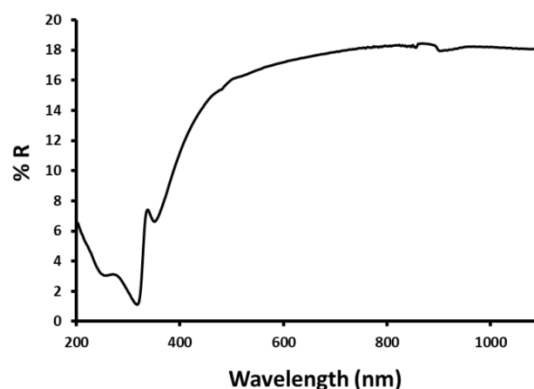


Figure S1: (a) SiNWs covered by dendrite layers of Ag, (b) Optical reflectance of SiNWs arrays covered with dendrite layers of Ag.

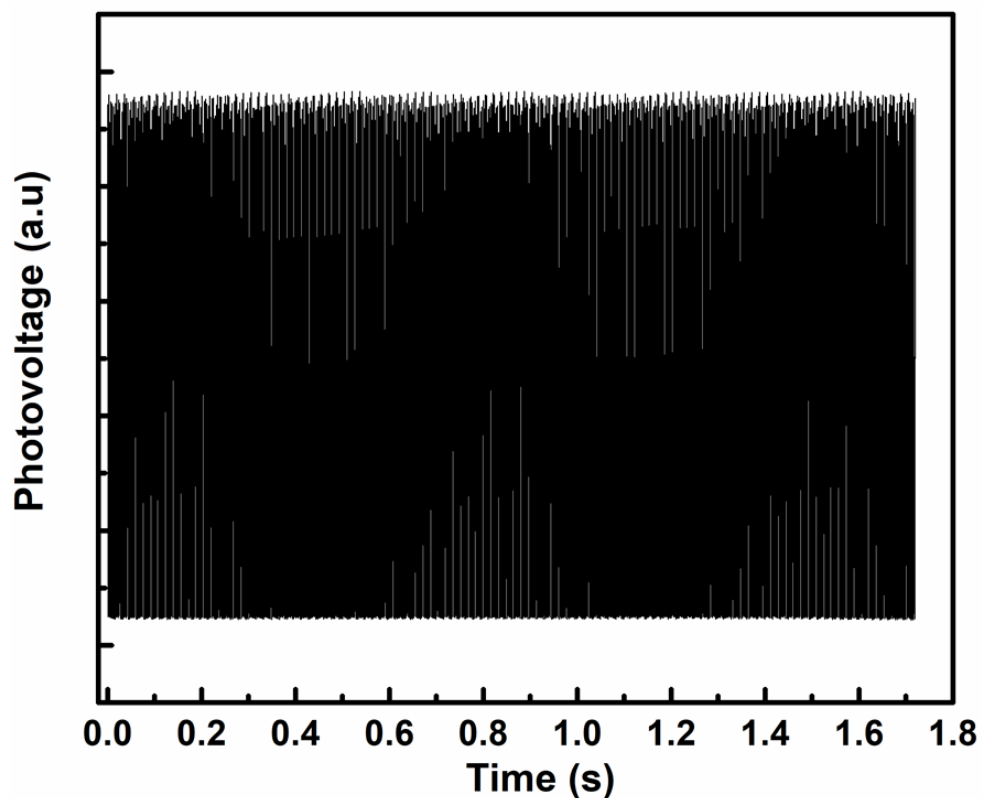


Figure S2: Stability measurement of the signal before the I-T measurements.

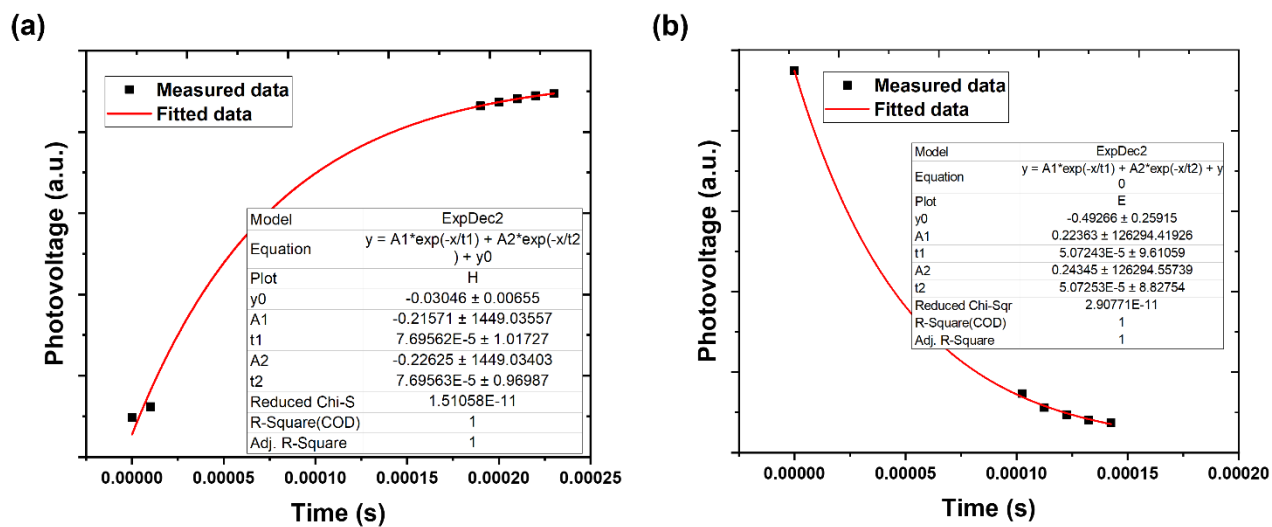


Figure S3: (a) Rise time calculation, and (b) Decay time calculation.